PATENT P56342

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:

DEOK-HYEON CHOE et al.

Serial No.:

to be assigned

Examiner:

to be assigned

Filed:

18 April 2001

Art Unit:

to be assigned

For:

TENSION MASK FOR COLOR CRT, METHOD FOR MANUFACTURING THE

TENSION MASK, AND EXPOSURE MASK USED IN THE MANUFACTURE

OF THE TENSION MASK

INFORMATION DISCLOSURE STATEMENT

Assistant Commissioner for Patents Washington, D.C. 20231

Sir:

In accordance with 37 C.F.R. §1.56, and §§1.97 and 1.98 as amended, Applicant cites, provides copies and discusses the following art references:

	Patent No.	<u>Inventor</u>	<u>Date</u>
•	4,942,332	Adler et al.	7/90
•	4,926,089	Moore	5/90

Adler et al.'332 discloses tied slit mask for color cathode ray tubes.

Moore'089 discloses tied slit foil shadow mask with false ties.

The citation of the foregoing references is not intended to constitute an assertion that other

or more relevant art does not exist. Accordingly, the Examiner is requested to make a wideranging and thorough search of the relative arts.

No fee is incurred by this Statement.

Respectfully submitted,

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